

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : Confirmation No. 4981

Hiroshi TAKANASHI et al. : Docket No. 2000-1749

Serial No. 09/739,750 : Group Art Unit 1752

Filed December 20, 2000 : Examiner S. Lee

NEGATIVE-WORKING PHOTOSENSITIVE RESIN COMPOSITION AND PHOTOSENSITIVE RESIN PLATE USING THE SAME

THE COMMISSIONER IS AUTHORIZED TO CHARGE ANY DEFICIENCY IN THE FEES FOR THIS PAPER TO DEPOSIT ACCOUNTING \$2.0975

NOTICE OF APPEAL

Assistant Commissioner for Patents, Washington, DC 20231 RECEIVED

DEC 2 3 2002

Sir:

TC 1700

Applicant hereby appeals to the Board of Appeals from the decision dated June 19, 2002 of the Primary Examiner finally rejecting claims 1 and 3 to 5.

- (X) A timely response to the final rejection has been filed.
- (X) The extension fee of \$520 for a third month extension of time is submitted with the attached Petition for Extension of Time.
- (X) The Appeal Fee of [X] \$320.00 (other than Small Entity)
 [] \$160.00 (Small Entity)
 - (X) is enclosed
 - () is to be charged to Deposit Account No. 23-0975. The original and two copies of this sheet are enclosed.
- () Small entity status of this application is established by the verified statement under 37 CFR 1.9 and 1.27 which
 - () is enclosed.
 - () has been previously submitted.

320.00 OP

() The Appeal Fee is not required since it was paid in a prior appeal.

Respectfully submitted,

Hiroshi TAKANASHI et al.

By

Matthew Jacob

Registration No. 25,154 Attorney for Applicants

MJ/jef Washington, D.C. 20006-1021 Telephone (202) 721-8200 Facsimile (202) 721-8250 December 19, 2002